

JC97105 PRO
09/893866
08/25/01

Class	Subclass	Issue Date

PATENT NUMBER

U.S. UTILITY Patent Application

O.I.P.E.

PATENT DATE

M.F. KCG Q.A. LR
SCANNED

APPLICATION NO. 09/893866	CONT/PRIOR	CLASS 349	SUBCLASS	ART UNIT 2871	EXAMINER
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APPLICANTS

Apostolos Voutsas

Method for forming silicon films with trace impurities

TITLE

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PTO-2040
12/99

ISSUING CLASSIFICATION

ORIGINAL		CROSS REFERENCE(S)			
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)		
INTERNATIONAL CLASSIFICATION					
<input type="checkbox"/> Continued on Issue Slip Inside File Jacket					

TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) _____ (Date)			NOTICE OF ALLOWANCE MAILED	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____ _____					
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	_____ (Primary Examiner) _____ (Date) _____ (Legal Instruments Examiner) _____ (Date)			ISSUE FEE	
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